

Special Issue

Gas Capture Processes

Message from the Guest Editors

This Special Issue on “Gas Capture Processes” aims to identify novel advances in the development and application of experimental and modeling work to address longstanding challenges in gas capture processes. Topics include, but are not limited to, the following:

- Gas separation from gas mixture;
- Optimization and comparison of the gas capture processes;
- Mechanism and thermodynamics of CO₂ and other phases;
- Multiphase flow during the capturing process; and
- The development of gas capture applicaitons.

Guest Editors

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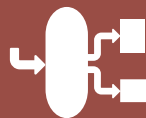
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Deadline for manuscript submissions

closed (15 September 2019)



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Editor-in-Chief

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